IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Toshiya IMAI, et al.

GAU:

-SERIAL NO: New Application

EXAMINER:

FILED:

Herewith

FOR:

NONLINEAR RESISTOR AND METHOD OF MANUFACTURING THE SAME

REQUEST FOR PRIORITY

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

SIR:

COUNTRY

- ☐ Full benefit of the filing date of U.S. Application Serial Number, filed, is claimed pursuant to the provisions of 35 U.S.C. §120.
- ☐ Full benefit of the filing date of U.S. Provisional Application Serial Number, filed, is claimed pursuant to the provisions of 35 U.S.C. §119(e).
- Applicants claim any right to priority from any earlier filed applications to which they may be entitled pursuant to the provisions of 35 U.S.C. §119, as noted below.

In the matter of the above-identified application for patent, notice is hereby given that the applicants claim as priority:

APPLICATION NUMBER

will be submitted prior to payment of the Final Fee

Japan		11-282871	October 4, 1999
Japan		2000-262950	August 31, 2000
Certified copies of the corresponding Convention Application(s)			
	are submitted herewith		
	will be submitted prior to payment of the Final Fee		
	were filed in prior application Serial No. filed		
	were submitted to the International Bureau in PCT Application Number. Receipt of the certified copies by the International Bureau in a timely manner under PCT Rule 17.1(a) has been acknowledged as evidenced by the attached PCT/IB/304.		
	(A) Application Serial No.(s)	were filed in prior application Serial No. file	d ; and
	(B) Application Serial No.(s)		
	□ are submitted herewith		

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C.

Marvin J. Spivak

Registration No.

C. Irvin McClelland Registration Number 21,124

MONTH/DAY/YEAR

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